

## PATENT APPLICATION

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: TAKAHARU KONDO, ET AL. Application No.: 09/866,665		)	
		: ) : )	Examiner: Alan D. Diamond Group Art Unit: 1753
For:	SILICON-TYPE THIN FILM FORMATION PROCESS, SILICON TYPE THIN FILM, AND PHOTOVOLTAIC DEVICE	) : ) :	April 6, 2005
	Stop Amendment		
Com	missioner for Patents		
P.O.	Box 1450		
Alex	andria, VA 22313-1450		

Sir:

In response to the Office Action dated January 6, 2005, please amend the above-identified application as follows.

> I hereby certify that this correspondence is being deposited with the United States Postal Service as first-class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on April 6, 2005 (Date of Deposit)

> > 5hn A. Krause (Reg. No. 24,613) (Name of Attorney for Applicants)

April 6, 2005 Date of Signature